


iMiD 2022

The 22nd International Meeting on Information Display
August 23-26, 2022 / BEXCO, BUSAN, KOREA



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Exhibitor Introduction	<p>CN1: CAN NUMBER ONE A fast growing Korean player</p> <ul style="list-style-type: none">Can Number 1 (CN 1 was founded in 2008 and is based in South Korea CN 1 principally offers R&D dedicated equipment but is also starting to enter the production area Principal applications are PV, microOLEDs, AMOLEDs, catalyst, CNT and particle ALD as well as DRAM and fuel cells CN 1 grew quickly and started construction of new facilities in October 2020. The strength of the company lies in rapid adaptation of tools for client needs.CN1 is diversifying its business through an IP portfolio, frequent collaborations with domestic and international universities, tool customization, coating solutions and an ALD precursor/reactant canister supply with up to 200 liters of capacity with a dedicated delivery system i e direct liquid injector bubbler or bypass.More than 220 tools have been shipped, 195 to Korea and the rest	

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	<p>overseas Among its clients are many universities as well as industrial players. Furthermore, CN1 plans to enter the Chinese market with a Sino Singapore international joint research venture for organic LEDs and thin film technologies.</p>
Exhibit Description	<p>CN1 has become the leading supplier of Atomic Layer Deposition (ALD) equipment through aggressive investments in R&D. Our equipment designs and process technologies have been thoroughly proven and perfected over a decade of intensive development.</p> <p>As a result, high-tech organizations working in the semiconductor, display, bio-tech and advanced energy industries now prefer CN1 ALD systems to meet their most demanding nanotechnology applications and production needs.</p> <p>The proof is that CN1's ALD equipment is now in use at hundreds of leading Universities, Research Institutes and Companies in the United States, Japan, Singapore, Taiwan, Russia, China and Korea. Our successes to date and our continual drive to grow as a global company demonstrate that CN1 truly "Can be the Number One".</p>
Exhibit Product	<p>Products : Atomic Layer Deposition</p> <p>For R&D (Single wafer)</p> <ol style="list-style-type: none">1. Atomic Premium2. Atomic Classic3. Atomic Shell <p>For Production (Batch Tool)</p> <ol style="list-style-type: none">4. Atomic Mega5. Cluster System (Multi-chambers)6. Atomic Batch